## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Attorney Docket No.: In re application of: Hui-Lin Chang et al. TS02-1079/24061.500 9999999 Group Art Unit: 1765 Serial No.: 10/666,354 Filed: September 19, 2003 Examiner: Angadi, Maki A.

For: Two Step Post-Deposition Treatment of ILD Layer for a Layer Dielectric Constant and Improved Mechanical Properties Š

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Certificate of Service I hereby certify that this correspondence is being filed with the U.S. Patent and Trademark Office via EFS-Web on October 25, 2006.

Conf. No. 8188

## RESPONSE TO OFFICE ACTION

Sir:

No fees, including extension of time fees, are believed necessary for consideration of the present paper. However, if any fees, including extension of time fees, are necessary, the extension of time is hereby requested, and the Commissioner is hereby authorized to charge any fees, including those for the extension of time, to Havnes and Boone, LLP's Deposit Account No. 08-1394.

In response to the Office Action of August 4, 2006, please amend the above-identified application as follows:

Listing of claims begins on page 2 of this paper.

Remarks begin on page 8 of this paper.